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Title of Invention	Method of Selective Deposition of Heavily Doped Epitaxial SiGe	
Application Number :	10/683937	
Date :	2003-10-10	
First Named Applicant:	Kim Yihwan	
Confirmation Number:	2191	
Attorney Docket Number:	AMAT8539TSGEPIRKK	
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Submitted By:	Elec. Sign.	Sign. Capacity
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Documents being submitted:	Files
us-ids	AMAT8539TSGEPIRKK-usidst.xml us-ids.dtd us-ids.xsl
Comments	